Enhancing the Accuracy of Manufacturing Process Error Detection through SMOTE-based Oversampling Using Machine Learning and Deep Learning Techniques

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[05, 2023]

Certificate

Date: 21-May-23

This is to certify that the work present in this Project entitled "**Enhancing the Accuracy of Manufacturing Process Error Detection through SMOTE-based Oversampling Using Machine Learning and Deep Learning Techniques**" has been carried out by **Boyapati Sai Venkat, Maryada Rishitha and Guduru Bhanu Sri Rakshitha** under my supervision. The work is genuine, original, and suitable for submission to the SRM University – AP for the award of Bachelor of Technology in the **School of Engineering and Sciences**.

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Affiliation.

Acknowledgments

We would like to take this opportunity to express our sincere appreciation and gratitude to all those who have contributed to the successful completion of our final project.

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Table of Contents

Abbreviations

SECOM	Semiconductor Manufacturing
LR	Logistic Regression
DT	Decision Tree
XGBoost	Extreme Gradient Boosting
RF	Random Forest
SVM	Support Vector Machine
NN	Neural Network
RUS	Random Undersampling
ROS	Random Oversampling
SMOTE	Synthetic Minority Over-sampling Technique
SVM SMOTE	Support Vector Machine Synthetic Minority Over-sampling Technique
B-SMOTE	Borderline Synthetic Minority Over-sampling Technique
TP	True Positive
TN	True Negative
FP	False Positive
FN	False Negative

Abstract:

A production competence analysis results in an increase in the strategic focus of the manufacturing sectors. Developing Semiconductor materials is a highly complex approach that necessitates numerous evaluations. It is impossible to emphasize the significance of the quality of the product in this regard. We analyze a handful of these scopes of study in this work and then propose machine learning strategies to automatically develop an efficient prognostic model for predicting equipment defects throughout the wafer production process of the semiconductor materials.

The SECOM dataset is representative of semiconductor production procedures that go through numerous tests performed. There are imbalanced statistics in the dataset, so our proposed methodology incorporates SMOTE functionality that is introduced to mitigate the imbalance of the training dataset by leveling off any unbalanced attributes. Detecting faults in the manufacturing process improves semiconductor quality and testing efficiency, and is used to validate both approaches to Machine Learning and Deep Learning algorithms. This is accomplished by collecting performance metrics such as accuracy and f-score during the development process. Another aspect of our effort to cut down on the training time for semiconductor testing is highlighted in our research report.

Keywords:

Semiconductor, Manufacturing process errors, SECOM dataset, Wafer production, Training and Testing data, Imbalance data, Balance Data, Machine Learning, Deep Learning, SMOTE technique, Logistic regression, Decision tree, Support Vector Machine, Random Forest algorithm, Neural Network.

Introduction:

The corporate setting of modern times is constantly evolving. The development of semiconductors has significantly altered our world [1]. Without a doubt, semiconductors drastically transformed the world in ways that were unimaginable before. One brief paper needs to adequately cover semiconductors' lengthy and complex history. Past studies clearly demonstrate that Semiconductors are substances that exhibit conductivity intermediate between that of conductors and that of non-conductors or insulators.

The primary objective of semiconductor manufacturers is to raise their quality on an annual basis. Because semiconductors form the foundation of every hardware system, the demand for them has increased tremendously along with both the personal and business use of all technologies. If we look at the beginnings of all of it, Alessandro Volta coined the phrase "semiconducting" at the initial moment in 1782. Michael Faraday (1833) made the earliest known discovery of a semiconductor effect when he found that, in contrast to the dependency seen in metals, the resistance of silver sulfide dropped with temperature.

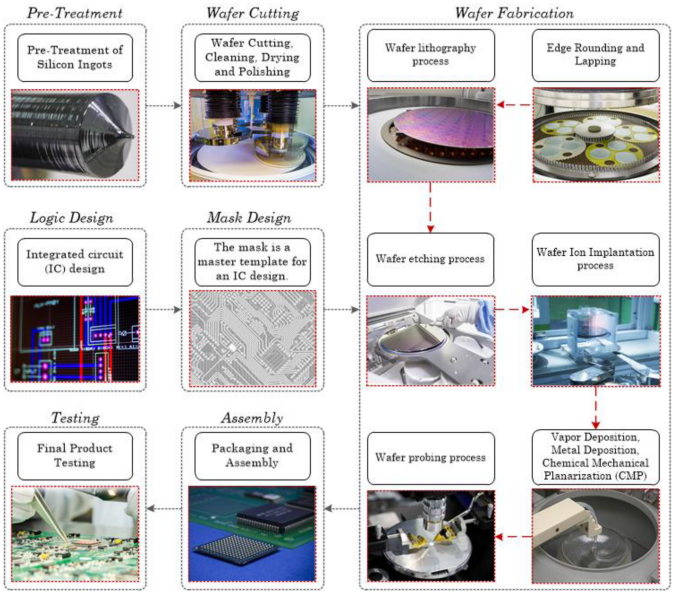


Figure 1: A succinct illustration of the semiconductor manufacturing process [2]

Machine learning, data mining, and deep learning offer a multitude of possibilities for the efficient management of industrial processes. By means of distributed data collection, data cleansing, extracting useful data from noisy data, and updating optimization ideas from flowing data in real time, these technologies can provide a wealth of opportunities for industrial applications [3]. These kinds of methodologies enable the development of a model for the segmentation of process data, and on the basis of this model, the realization of effective predictions for unlabeled data. These changes produced enormous volumes of data that need to be evaluated. This article suggests machine learning and deep learning methods for evaluating manufacturing process failures.

The production of semiconductors is the industry that is taken into account for the validation of these processes. Predicting process faults is crucial for reducing failure rates and producing usable products since a correctly made semiconductor is suitable for industry, free of manufacturing flaws, and has a low likelihood of failing functional testing. The SECOM dataset serves as a support for comparing our suggested methodologies and is indicative of semiconductor manufacturing operations. This dataset acts as the norm for assessing if the deliverables of a series of manufacturing activities are incorrect or not. It conducts numerous tests on the semiconductor and assesses its functional capability to see if it is functioning properly. These assessments measure if the semiconductor is operating properly or not, and in our dataset, we have a significant quantity of data from several semiconductors that were undertaking these checks. The results of the tests indicate whether the semiconductors were successful or not.

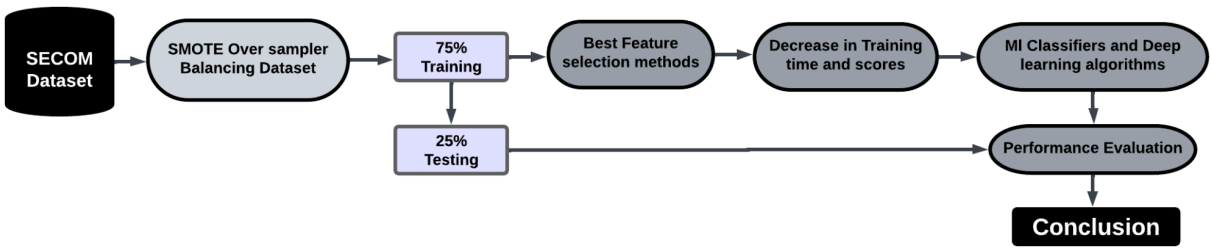


Figure 2: Proposed Methodology for SECOM Dataset workflow.

Below is a brief outline of this article's workflow and key contributions [4]:

- Determining an approach that utilizes the following processes for spotting faults in the manufacturing process which are data preprocessing which involves data cleaning and it corrects the noisy data, features selection, and dataset will be splitting into train and test data.
- Before doing these data preprocessing techniques SMOTE operation is applied to correct the class imbalance data.
- Eliminating unimportant features results in a significant reduction in training time and improved model performance.
- The modification, applying as well as assessment of the deep learning and machine learning algorithms. The SECOM dataset measurement of the suggested techniques.

Additionally, the document is structured as follows: Section II describes Related works, Section III presents the Dataset description, Section IV tells about all the methodologies used in model building and assessment, and Section V takes us through the complete workflow which is the proposed methodology, Section VI presents the performance evaluation of all the machine learning and deep learning techniques applied, Section VII companies all the results while Section VIII presents the conclusions and at the end, our paper ends with mentioning all the references used throughout the research.

Related Works:

The initial literature papers about our topic actually assist us in first comprehending the importance, manufacturing techniques, and testing procedures for semiconductors. Using earlier articles as a guide, Let's now talk about the methodologies that numerous other published studies use.

Balancing the Dataset as the dataset is faulty data balancing is the main part. Kim et al [5] and Salem et al [6] authors employed the SMOTE technique to balance the dataset. Their results indicated that SMOTE-based oversampling could help improve fault detection in semiconductor manufacturing processes. Salem et al [6] authors tested 288 approaches to classifying the SECOM dataset using various stages for data imputation, data imbalance, feature selection, and classification. The results showed that LR was the best classification model, and SMOTE was the best technique for synthetic data generation. Moldovan et al [8] tested their method on two datasets, SECOM and SETFI, and found that using the CSO algorithm to determine the number of nodes in each hidden layer increased the weighted precision of the MPC.

Feature Elimination enhances model performance by selecting pertinent features and noise, resulting in improved accuracy and efficiency. Salem et al [6] the authors used SELECTFDR to be effective for feature selection, and "In-painting KNN-Imputation" was the best data imputation method. These discoveries have the potential to improve the accuracy and reliability of fault detection in semiconductor manufacturing processes. Extensive analysis of research papers revealed a focus on reducing training time by identifying relevant features. Increased feature count was consistently linked to longer training times. Consequently, feature elimination techniques were utilized to select informative features, reducing training time while maintaining model performance. Furthermore, apart from the aforementioned techniques, there exists a range of other methods for feature elimination, such as Principal Component Analysis (PCA), Multivariate Adaptive Regression Splines (MARS), and NOVA [11]. These approaches

provide alternative strategies to select important features, thereby enhancing the performance of classification models across diverse domains and industries [12].

Classification is the crucial stage of evaluating product quality, and classification models have been extensively utilized. Various studies have explored different approaches. Kim et al [5] authors developed fault detection prediction models using logistic regression (LR), artificial neural networks (ANN), decision trees (DT), and random forests (RF). Kerdprasop and Kerdprasop [7] researchers have also proposed data mining-based fault detection methods, with Naive Bayes achieving a 90% fault detection rate but an 80% false alarm rate. To address this, boosting techniques were employed, resulting in improved precision for tree-based models while maintaining a low false alarm rate. Multilayer Perceptron Classifier (MPC) and Chicken Swarm Optimization (CSO) were employed in other studies by Moldovan et al [8]. Additionally, classification performance has been explored using support vector machines, logistic regression, artificial neural networks, and decision tree algorithms by Munirathinam [9] and Karthigaikumar [10]. These studies highlight the continuous efforts to develop effective models for product quality prediction and fault detection in the semiconductor manufacturing industry.

Dataset Description:

The SECOM Dataset was discovered by authors Michael McCann and Adrian Johnston and was donated to the UCI Machine Learning Repository on the 19th of November, 2008. This research utilizes the SECOM (Semiconductor Manufacturing) dataset, which includes both manufacturing operation data and semiconductor quality data, to determine the quality of semiconductors produced in the industry [13]. The dataset is derived from the semiconductor manufacturing industry and is highly skewed. Its objective is to classify semiconductors as either good or bad based on the manufacturing process. The dataset comprises 1567 instances with two classes, 104 fails, and some missing values.

The SECOM Dataset poses a two-class problem, but there is an imbalance in the distribution with a 14:1 skew of the pass to fail. With a total of 590 features, this dataset presents a significant number of variables. However, missing data and incomplete Feature information are prevalent throughout the dataset. Additionally, a few columns consist of constant values, further adding to the dataset's unique characteristics [14]. The SECOM dataset is composed of 1567 examples that originate from a wafer manufacturing production line. Each example in the dataset is represented by a vector of 590 sensor measurements and includes an identification for pass-fail testing. Out of the total examples, only 104 are marked positive as failed cases, coded as 1, while the majority of examples pass the test and are marked negative, coded as -1. This significant class imbalance poses a challenge in achieving a good balance between the precision and recall of the classifier. Furthermore, analyzing the dataset accurately is challenging due to the large amount of measurement data collected from hundreds of sensors, combined with the imbalance between pass and fail examples.

The dataset is composed of 1567 examples that originate from a production line. Each example in the dataset is represented by a vector of 590 sensor measurements and includes an identification for pass-fail testing. It also includes a date-time stamp corresponding to the functionality test. The dataset contains null values, which vary in intensity depending on the individual features. These null values correspond to data points with no recorded measurements in the original metrology data.

Model Building and Assessment:

As we know, there are two methods for balancing a dataset: oversampling and undersampling. We initially used the undersampling technique, specifically the random undersampling, to balance our data by reducing the number of case conditions. However, we found that this approach was not particularly helpful since fewer case conditions result in lower prediction accuracy [15]. Therefore, we decided to try out oversampling techniques and tested various options such as

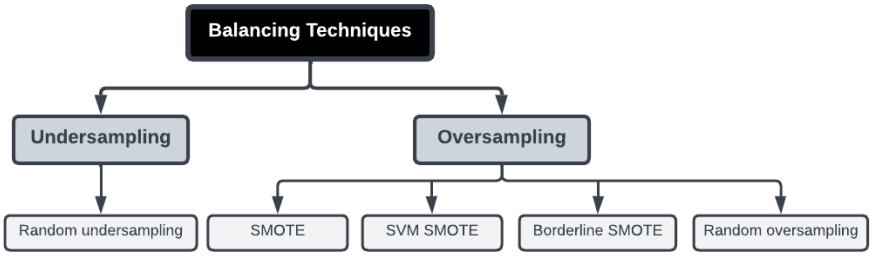


Figure 3: Different Types of Balancing Techniques

- **RandomUndersampler:**
  RandomUndersampler randomly selects instances from the majority class to address imbalanced datasets. It helps balance class distribution, reduces bias, and improves model learning. Careful consideration of the dataset and problem context is crucial before applying RandomUndersampler or other resampling techniques. In our project, we encountered skewed data with a majority of negative instances. To address this issue and improve the outcome, we applied undersampling using RandomUndersampler. By reducing the data from the majority. Because there were fewer cases to examine, the outcome is not accurate.

- **Random Oversampling:**
  Random Oversampling is a technique to address the class imbalance by duplicating instances from the minority class. However, it may lead to overfitting or loss of information. Evaluating its effectiveness and considering alternatives like SMOTE or ADASYN, which employ more advanced procedures, is crucial for better outcomes. Implementing randomoversampler, we synthetically increased positive data rows to balance the dataset, mitigating bias in our analysis or machine learning model. This technique played a vital role in attaining a balanced dataset, alleviating class imbalance, and obtaining accurate results reflective of our model's performance.

- **SVM SMOTE:**
  SVM SMOTE combines SVM with SMOTE to tackle class imbalance, generating synthetic samples for the minority class during oversampling. It excels in high-dimensional feature datasets, enhancing classification accuracy for imbalanced data. We observed that the SVM SMOTE did not efficiently balance the data by

increasing the case conditions during its deployment in our project. As a result, the outcomes were flawed.

- **Borderline SMOTE:**
  Borderline SMOTE addresses class imbalance by creating synthetic instances at the decision boundary and improves classification accuracy, especially with noisy and overlapping datasets. This approach effectively created a balanced dataset for our project by incorporating positive case scenarios, which led to improved results and overall performance.

Upon thorough examination of several papers, we acquired knowledge about a range of algorithms that exhibited superior performance in this particular area. Armed with this information, we proceeded to implement these high-performing algorithms in conjunction with a select few others, which are detailed below [16].

- ## Logistic Regression:

  Logistic regression is performed when dealing with a classification issue. It is employed to determine the relationship between characteristics and the likelihood of a specific result. In our instance, the possibility will fall between 1 and 0 (pass or fail). To determine the probability, we generally employ the logistic function or the sigmoid function.

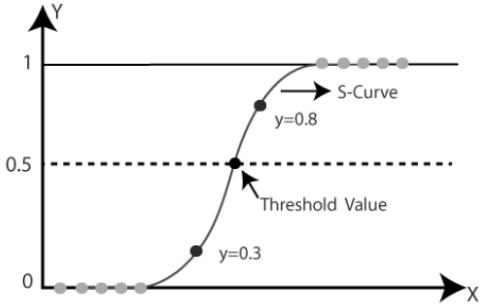


Figure 4: Classification based on logistic regression

- ## Decision Tree Classifier:

  A decision tree is a visual representation of choices and their outcomes, typically depicted as a tree-like graph. The graph consists of nodes, which represent a specific event or choice, and edges, which provide the conditions or rules necessary for making decisions. In every decision tree, there are branches and nodes, with each branch indicating a possible value for the node, and each node representing a set of characteristics that must be classified.

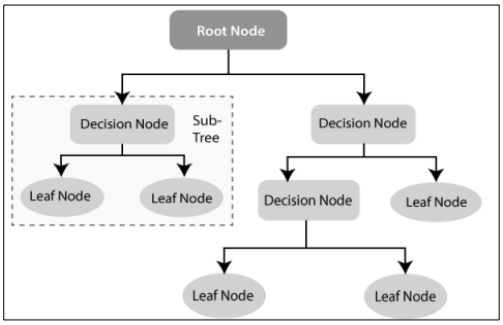


Figure 5: Decision Tree

- **Support Vector Machine (SVM):**

  In order to classify the data points into two groups, the SVM algorithm searches for the optimal line to do so. SVM examines the data used in classification and regression analysis. Support vector machines (SVMs) can effectively perform non-linear classification as well as linear classification by implicitly converting their inputs into high-dimensional feature spaces.

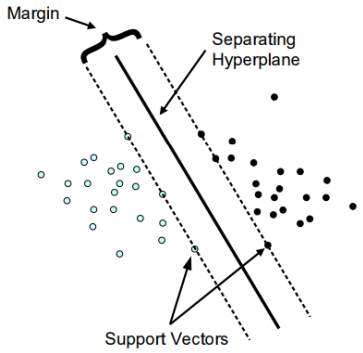


Figure 6: SVM Classification linear separable

- **Extreme Gradient Boost Classifier (XGBoost):**

  A decision tree that learns from the residuals of earlier predictor variables is the Extreme Gradient Boost Classifier. XGBoost works by training a variety of decision trees. Each tree is trained using a portion of the data. The final forecast is then obtained by combining the predictions from each tree. It is the best machine-learning tool for problems like regression, classification, and ranking and provides parallel tree boosting.

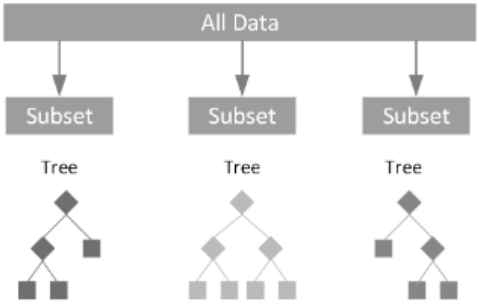


Figure 7: XGBoost

- **Random Forest Classifier:**

  The Random Forest model is an ensemble learning approach that, during the training phase, creates several decision trees. In a random forest, each decision tree is built using a subsample of features rather than each decision tree is built using all characteristics. Trees then predict a class outcome, and the model's final class prediction is based on the trees' consensus.

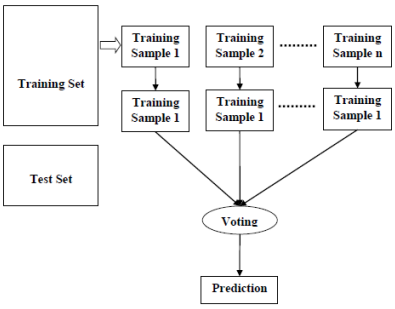


Figure 8: Random forest algorithm flow chart

- **Neural Networks:**

  Neural networks imitate the way the brain finds connections and patterns in data. Combining various numerical inputs yields a single numerical output with adjustable coefficient weights. Unlike conventional models, neural networks can modify their parameters in response to varying inputs, allowing them to produce optimal outputs without the need to adjust the output criterion.

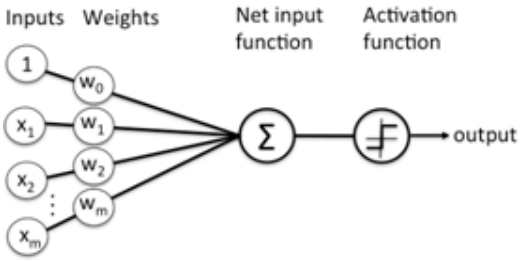
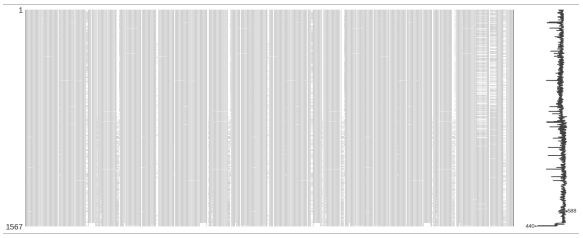


Figure 9: Flow of Neural Network

Proposed Methodology:

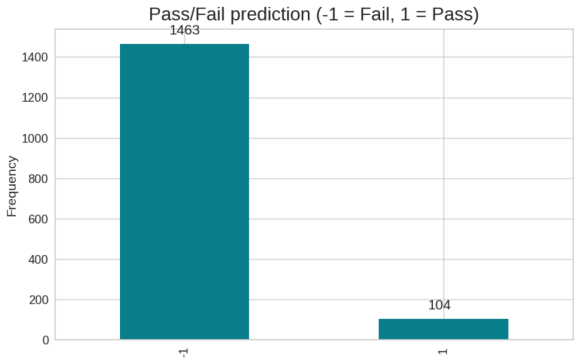
This research paper looks at some of the most prominent machine learning and deep learning algorithms for sensor-based manufacturing approaches. The proposed methodology is outlined, and the corresponding implementations are summarized in Figure 2. The dataset we worked with comprises 1567 records and 592 properties. We used a range of tools, including NumPy, pandas, sklearn, matplotlib, and many more, to conduct in-depth research. The msno function was used to check for missing values once we discovered them when cleaning the data. A graphical depiction of missingness patterns in a dataset, known as a matrix plot for missing values, enables you to quickly and accurately identify trends in missingness across several variables. The primary advantage of using a matrix plot for missing values is that it can aid researchers in developing better-informed decisions regarding handling missing data, resulting in more reliable and accurate data analyses. We found missing values in the dataset, which might significantly affect our conclusions.



Graph 1: Before removing missing values

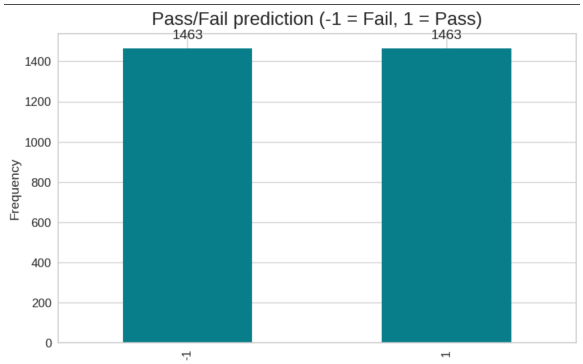
In order to identify any data imbalances, we displayed the pass/fail predictions. Then, we used the smote library to balance the dataset, and the results were then shown.

- **Before SMOTE:**



Graph 2: Imbalance dataset representation

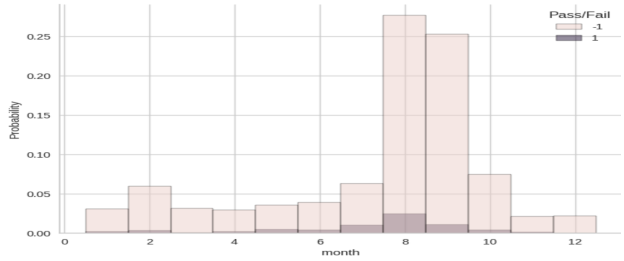
- **After SMOTE:**



Graph 3: Balanced dataset representation

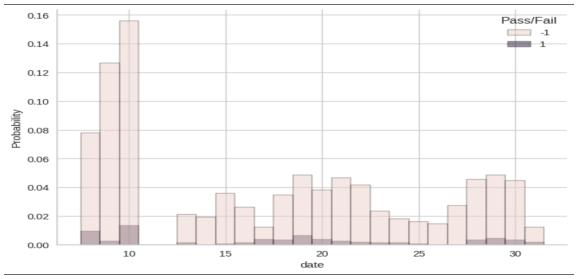
To prepare the data for analysis or modeling, we performed some preprocessing steps on the dataset. One of these processes was to divide the "timestamp" column, which enabled us to turn the timestamp values into a numerical format that could be expressed as a decimal integer. Moreover, we discovered and deleted some unnecessary columns, such as "start time." Using a unique function, we were able to retrieve a special weekday, year, month, and date. Here, we displayed various histograms, such as

- **Month Vs probability of Pass/Fail:**



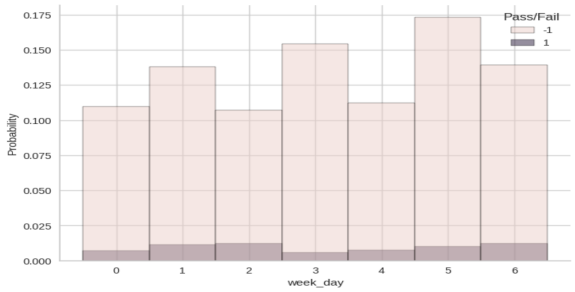
Graph 4: Pass/Fail Rates by Month

- **Date Vs probability of Pass/Fail:**



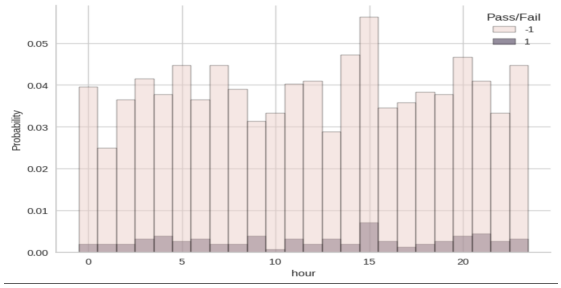
Graph 5: Pass/Fail Rates by Date

- **Week_day Vs probability of Pass/Fail:**



Graph 6: Pass/Fail Rates by weekday

- **Hour Vs probability of Pass/Fail:**



Graph 7: Pass/Fail Rates by hour

After importing the dataset into a pandas data frame and analyzing its rows and columns, significant imbalances in the target values were found. To resolve this issue, the target values were balanced using the SMOTE method. The data was then split into 75:25 training and testing sets using the train-test split approach. We used a dataset containing a variety of characteristics, the bulk of which were numerical. The information in a few columns, such as "year", "month", "date", "weekday", "hour", and "min," however, was not numerical. We carefully considered these features and determined that they were not necessary for our modeling or analysis, therefore we removed them from the dataset. By implementing the Synthetic Minority Over-sampling Technique (SMOTE), multiple data points are added to the dataset, which leads to a significant enhancement in the efficiency and accuracy of the model. This is primarily attributed to the fact that the additional data points aid in improving the feature engineering process. It has been observed that incorporating SMOTE has resulted in a reduction in training time compared to not utilizing SMOTE.

In our dataset, we encountered the challenge of missing values, which can hinder data analysis and modeling. To overcome this issue, we have implemented the KNN imputer.

- **KNN Imputer:**

  We handled missing values in our dataset by using the K-nearest neighbor (KNN) imputation method. KNN imputation utilizes the values of the nearest neighboring data points to fill in missing values [17]. We also created a graph to visualize the missing data, but it was subsequently removed after imputation. Initially, we removed columns with more than 30% missing values, eliminating 52 features. For the remaining missing samples (less than 30%), KNN imputation was applied. To prevent data leakage, the imputed data was modified only in the testing dataset. This approach led to a reduction in training time.

Graph 8: After removing missing values

Feature Elimination:

Our main objective was to significantly shorten the training period, therefore we used a number of techniques to do so. As part of our plan, the number of characteristics dropped, which significantly reduced training time [18]. The methods we used to do this are as follows:

- **Normalization:**
  Normalization was applied as a preprocessing step before implementing the variance threshold. The purpose of normalization is to adjust the scale of numerical data, reducing its sensitivity to different feature scales. It rescales the data to fit within the range of 0 to 1. Normalization plays a crucial role in enhancing the performance of machine learning models. Standardizing the feature scale ensures that no single feature dominates the learning process based solely on its magnitude. This helps prevent biased learning and improves the overall efficiency and accuracy of the models. This is particularly important when using distance-based algorithms, such as K-nearest neighbors or clustering algorithms, where the calculation of distances is highly influenced by the scale of features.

- **VarianceThreshold:**

  We noticed repeated values in corresponding rows, which hindered progress. To address this, we used the variance check method with a specific threshold (e.g., zero) to eliminate low-variance features. We imported a normalizer from sklearn and applied it to both the training and testing data to prevent data leakage. Features with a zero variance, indicating constant values that remained the same in each row, were removed. After this process, we were left with 590 features. We then utilized K-nearest neighbor imputation and reevaluated training time and outcomes.

- **Correlation:**

  To evaluate the correlations between features, we examined correlation coefficients (-1 to 1). Weakly correlated features (those close to 0) were deemed unimportant, whilst strongly correlated features (those near 1 or -1) were eliminated as redundant. We will exclude independent characteristics with a high absolute correlation since they are identical to other features and do not enhance our model. This left 264 features remaining after 214 features were removed, which then caused 214 further features to be removed. After this procedure, 264 important qualities were left.

- **Correlation With target:**

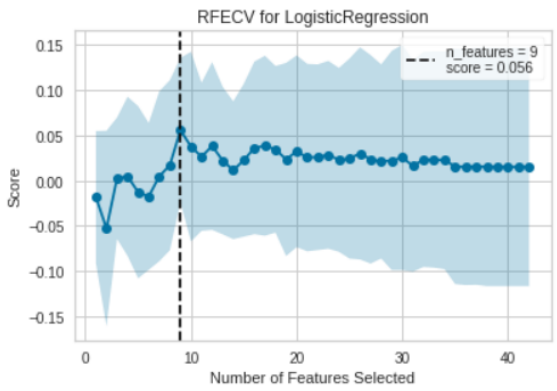
  Following the previous steps, we assessed the correlation between the remaining features and the target column. Features with a correlation below 5% were dropped. As a result, we identified 40 correlated features, while removing 224 features from the dataset.

- **Recursive Feature Elimination (RFE):**

  The RFE method recursively removes features from datasets until the desired number is attained. It is used for feature selection. It starts by building a model with all the components, then it takes off the feature that isn't as crucial and evaluates the model's performance. This technique is continued until the right number of features are generated. RFE is in fact quite efficient for high-dimensional datasets with plenty of attributes but few observations. To get a reduced feature set, we used the RFE approach. When we applied K-nearest neighbor imputation to this feature

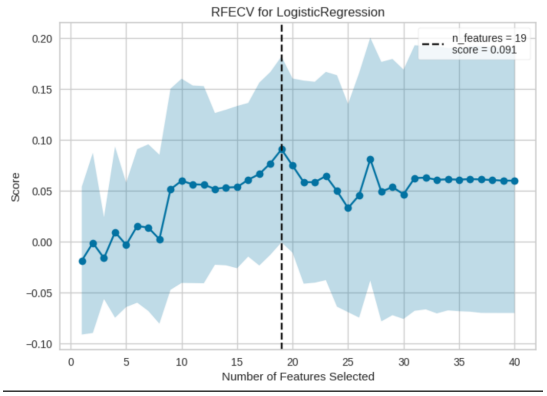
collection, the training time was dramatically reduced compared to the earlier "correlation with target" approach. The graph provides a visual representation of the recursive feature selection process and shows the optimal number of features for the logistic regression model.

- **Before SMOTE:**



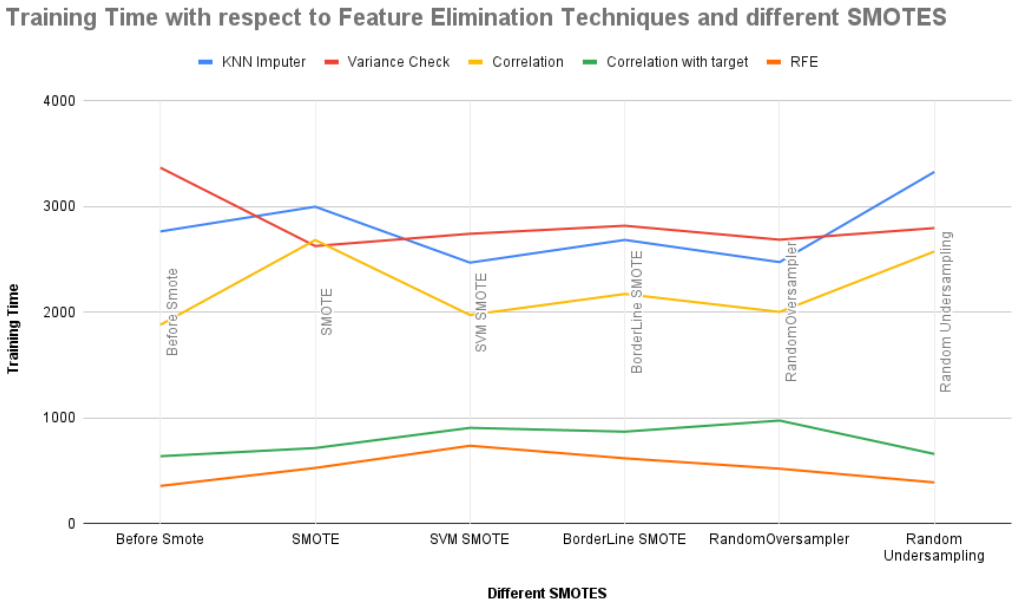
Graph 9: Number of features selected before smote.

- **After SMOTE:**

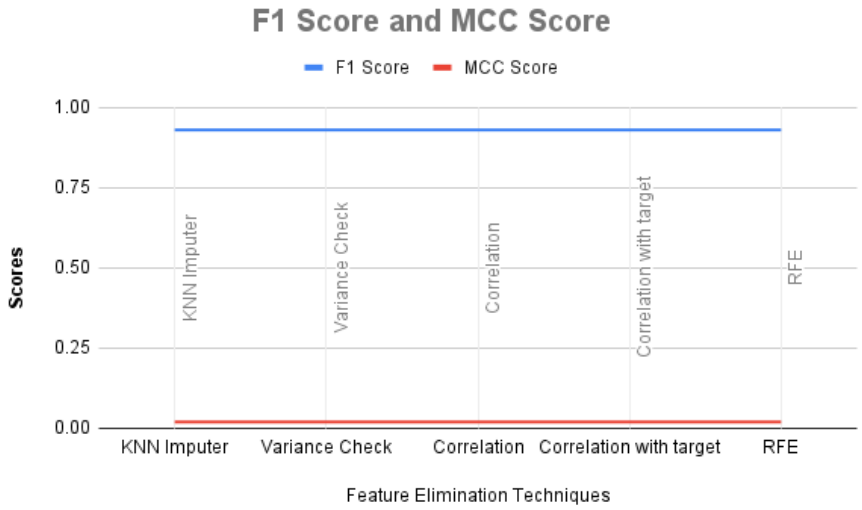


Graph 10: Number of features selected after smote

Initially, the analysis concentrated on examining 9 attributes prior to incorporating SMOTE. However, after the integration of SMOTE, the selection process identified a total of 19 features. Upon implementing the undersampling technique, the feature count remained unchanged compared to the scenario without undersampling, attributed to the reduced case conditions. Likewise, upon employing various oversampling techniques and enhancing the case conditions, the feature count remained constant across all oversampling techniques. A visual representation is provided below, outlining the associated training time at each stage of the feature engineering procedure. Despite the reduction in training time, the model's MCC Score and F1 Score have remained unchanged.



Graph 11: Training Time



Graph 12: F1 and MCC Score

Performance Evaluations for Machine Learning & Deep Learning Techniques:

We employed several algorithms, including Logistic Regression, Random Forest Classifier, Decision Tree Classifier, Extreme Gradient Boost, K-Nearest Neighbor, and Neural Networks, to generate performance metrics such as Accuracy, Recall Accuracy, Precision Accuracy, and F1 Score [19].

- **Classification Accuracy**

  In order to calculate the percentage of cases that have been correctly categorized out of all instances that have been classified, we may utilize the classification accuracy metric. When a positive instance is accurately predicted by the model, this is known as a True Positive (TP), and a negative example is correctly predicted by the model when it produces a True Negative (TN). When the model incorrectly predicts a positive case, it results in a False Positive (FP), whereas an inaccurate prediction of a negative instance is referred to as a False Negative (FN).

  $$Accuracy = \frac{TP+TN}{TP+FP+TN+FN}$$

- **Precision**

  A crucial parameter for assessing the effectiveness of machine learning models is precision. It is derived by dividing the total number of projected positives—both right and incorrect—by the number of true positives. This statistic gives an indication of how effectively a model can separate actual positive outcomes from all of its other positive predictions. Precision is essentially a measure of the proportion of true positive forecasts to all positive predictions. Every successful prediction made by the model has a precision score of 1, which is perfect. A score of 0 on the other hand means that no accurate positive predictions were generated by the model.

  $$Precision = \frac{TP}{TP+FP}$$

- **Recall:**

  Recall, typically referred to as sensitivity or true positive rate, is a crucial parameter used to assess how well a classification model performs. To determine it, the total number of actual positive events is divided by the number of true positive forecasts. A score of 0 means that no positive cases were correctly identified, whereas a perfect recall score of 1 means that all of them were.

  $$Recall = \frac{TP}{TP+FN}$$

- **F1 Score**

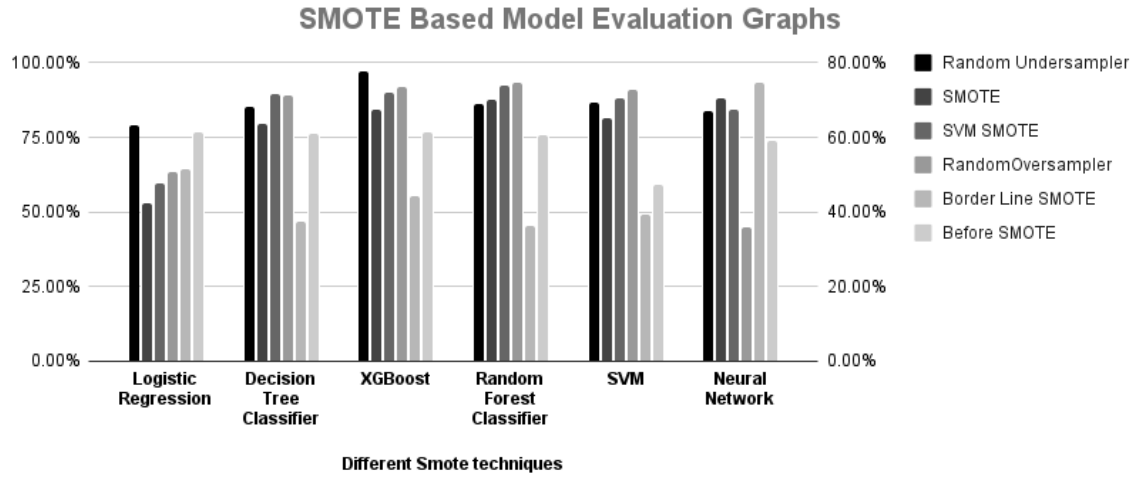
  The F1 score is an essential evaluation metric that combines recall and precision to give an overall assessment of an algorithm's performance. Low false positive and false negative scores, which show that the model correctly anticipated the results, are required to have a strong F1 score. The F1 score, a balanced statistic that weighs both recall and accuracy, has a value between 0 and 1. A score of 1 denotes the classification algorithm's strong performance, while a score of 0 denotes its weak performance. The F1 score is thus an effective tool for assessing the efficacy of classification algorithms and for contrasting the performance of various models.

  F- measure= (2* Recall * Precision)/(Recall + Precision)

After implementation of the machine learning techniques such as Logistic Regression, Decision Tree Classifier, Support Vector Machine, Random Forest Classifier, and XGBoost Classifier, as well as deep learning techniques such as Neural Networks to the SECOM dataset, we are presenting the results in a tabular and graphical format which makes it easy to understand in a concise manner.

Table 1: Accuracy of different classifications w.r.t different SMOTE techniques.

Accuracy	Random Undersampler	SMOTE	SVM SMOTE	Random Oversampler	Borderline SMOTE	Before SMOTE
Logistic Regression	63.27%	52.81%	59.44%	63.52%	64.29%	76.53%
Decision Tree	68.11%	79.59%	89.54%	89.03%	46.68%	76.02%
XGBoost	77.81%	84.18%	90.05%	92.09%	55.36%	76.79%
Random Forest	68.88%	87.50%	92.35%	93.37%	45.41%	75.77%
SVM	69.39%	81.63%	88.27%	90.82%	49.23%	59.18%
Neural Network	67.09%	88.27%	84.18%	44.90%	93.26%	73.98%



Graph 13: Result Analysis of Performances

The graph provided above illustrates the evaluation of multiple classifiers, both before and after employing the SMOTE. Initially, only one classifier demonstrated a significant improvement in performance compared to the others. Specifically, the Random Forest classifier achieved the highest accuracy rate of 93%.

Table 2: SMOTE versus Models.

SMOTE Vs Models	Best Model	Accuracy
Before Smote	SVM	93.26%
Random Undersampling	Neural Network	76.53%
SMOTE	XGBoost	89.54%
SVM SMOTE	Random Forest	92.09%
Random Oversampler	Random Forest	93.37%
BorderLine SMOTE	Random Forest	90.82%

Among the various SMOTE methods tested, the random oversampling yielded the best results when compared to Borderline SMOTE and SVM SMOTE. Additionally, machine learning surpassed deep learning in terms of accuracy. However, the introduction of SMOTE led to a substantial improvement in the number of well-performing classifiers. Notably, the Random Forest (RF) and XGBoost classifiers exhibited superior performance, achieving accuracy rates of 93% and 92% respectively, outperforming the other classifiers.

Table 3: Best scores in Machine Learning versus Deep Learning.

	Machine Learning	Deep Learning
Accuracy	93.37%	70.41%
Recall	100.00%	95.62%
Precision	93.37%	71.58%
F1 Score	96.57%	81.88%

Although the disparity in neural network performance with and without SMOTE was not substantial, there was a slight improvement in accuracy after implementing SMOTE techniques. The table above showcases the comparison between machine learning and deep learning techniques, highlighting the best-performing machine learning technique in contrast to deep learning. These results serve as a compelling demonstration of how the application of SMOTE has the potential to enhance the performance of a model.

Conclusion:

This study investigates how the combination of different SMOTE techniques and machine learning methods can effectively detect defects in manufacturing processes. The research findings highlight that employing various SMOTE methods significantly enhances the accuracy, precision, recall, and f-score of the classifiers by creating superior features. Prior to implementing SMOTE, only the RF classifier demonstrated satisfactory results, but after applying SMOTE techniques, particularly the random oversampling approach, both the RF and XGBoost classifiers exhibited the most promising performance in predicting manufacturing defects. These findings emphasize the crucial role of SMOTE and feature selection methodologies in improving the effectiveness of machine learning algorithms for detecting faults in manufacturing processes, leading to greater efficiency and accuracy.

Looking ahead, the results of this study hold considerable potential for the application of machine learning in the manufacturing industry. The incorporation of feature selection approaches successfully decreased the number of features, which resulted in a successful reduction in training time. By integrating various SMOTE techniques and feature selection methods, it becomes possible to develop more precise and efficient monitoring systems for manufacturing processes, thereby reducing defects and enhancing product quality. Additionally, the study suggests exploring alternative feature selection techniques to further enhance machine learning performance in detecting faults during manufacturing processes, offering new avenues for future research in this field.

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